Physics of Electronics: 7. Junction Diodes

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Contents overview

- Continuity equation.
- Semiconductor measurements.
- Pn junction in equilibrium.
- Current flow in a pn junction with forward bias.

Continuity Equation for Minority Carriers

• General considerations:

- Two main causes for the variation: Generation and loss & Drift

- No current flow (no gradient & no \mathscr{E})
 - Let's consider a p-type material:

dn/dt = G - R with: G = G(T) & R = r n(t) p(t)

– Equilibrium:

 $dn/dt = 0 \implies G(T) = rn_0 p_0 = rn_i^2$

- Variations from the equilibrium: $n = n_0 + \delta n \implies p = p_0 + \delta p \quad \text{with} \quad \delta n = \delta p$ $\implies [d(\delta n)/dt]|_{J=0} = -rp_0 \delta n = -\delta n/\tau_{Le}$

– For a **n-type** material:

 $d(\delta p)/dt = -\delta p/\tau_{Lh}$



Continuity Equation for Minority Carriers

• With current flow



• Total continuity equation

$$\frac{\partial(\delta n)}{\partial t}\Big|_{total} = -\frac{\delta n}{\tau_{Le}} + \frac{1}{e}\frac{\partial J_e}{\partial x} \quad (\text{idem for holes})$$

But $J_e = ne\mu_e \mathscr{E} + eD_e \nabla n \xrightarrow{n=n_0 + \delta n} \frac{\partial(\delta n)}{\partial t} = -\frac{\delta n}{\tau_{Le}} + \mu_e \mathscr{E}_x \frac{\partial(\delta n)}{\partial x} + D_e \frac{\partial^2(\delta n)}{\partial x^2}$

• Hall effect



• Using he Hall angle:

$$\tan \theta = \mathscr{E}_{y} / \mathscr{E}_{x} \quad \Longrightarrow \quad \tan \theta = \frac{J_{x} B_{z}}{p e} \frac{\sigma}{J_{x}} = \mu_{h} B_{z} \quad \Longrightarrow \quad \mu_{h} = R_{H} \sigma$$

- Hall effect
 - Consider both type of carriers to be present:

$$v_{\mathrm{Dh}} = \mu_{\mathrm{H}} \mathscr{E}_{\mathrm{x}} \qquad \qquad F_{\mathrm{h}} = -e(v_{\mathrm{Dh}} \times B) = -ev_{\mathrm{Dh}} B_{z}$$
$$v_{\mathrm{De}} = -\mu_{\mathrm{H}} \mathscr{E}_{\mathrm{x}} \qquad \qquad F_{\mathrm{e}} = e(v_{\mathrm{De}} \times B) = -ev_{\mathrm{De}} B_{z}$$

• A net current is created in the y direction

$$\sigma \mathscr{E}_{y} = e(pv_{yh} - nv_{ye})$$

- Now, using the expressions for the Hall angle
- $v_{yh} = \mu_h \mathscr{E}_y = \mu_h (\mathscr{E}_x \tan \theta) = \mu_h (\mathscr{E}_x \mu_h B_z) \qquad \& \qquad v_{ye} = \mu_e^2 \mathscr{E}_x B_z$

$$\Rightarrow \sigma \mathscr{E}_{y} = e(p\mu_{\rm h}^{2} - n\mu_{\rm e}^{2})\mathscr{E}_{x}B_{z}$$

• Four-point probe method for conductivity meas.

– Consider $d \ll L$



For the current leaving *A*:

$$J_r = I/(2\pi r^2) \implies \mathscr{E}_r = J/\sigma = I/(2\pi\sigma r^2)$$

Potential at a distance *a* from *A*:

$$V_{a} = \int_{-\infty}^{a} \mathscr{E}_{r} dr = -\frac{I}{2\pi\sigma} \int_{-\infty}^{a} \frac{1}{r^{2}} dr = \frac{I}{2\pi\sigma a}$$
$$\implies V_{BC} = \frac{I}{2\pi\sigma d} - \frac{I}{2\pi\sigma(2d)} = \frac{I}{4\pi\sigma d}$$

Identically for the current entering **D**, then:

$$V = 2V_{\rm BC} = \frac{I}{(2\pi\sigma d)}$$
$$\sigma = \frac{1}{2\pi d} \frac{I}{V}$$

• Minority carrier life-time and mobility.



Mobility:

$$v_{\rm D} = d/t_0 \quad \Longrightarrow \quad \mu E = \mu V/l = d/t_0$$

 $\downarrow \mu = ld/t_0 V$

Life-time:

 $d(\delta p)/dt = -\delta p/\tau_{Lh} \implies \delta p = \delta p_0 \exp(-t/\tau_{Lh})$

• Consider a pn junction with abrupt transition



Initially, the density of carriers change abruptly at the junction.

• Consider a pn junction with abrupt transition



This change of concentration causes diffusion which is stopped by exposition of ionized impurities at the transition (called depletion layer $\sim 1\mu$ m).

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In equilibrium, a voltage difference is created across the depletion layer.

- Voltage across the depletion layer
 - Start with continuity eq. for holes



– Idem for electrons

 $n_{\rm n} = n_{\rm p} \exp(eV_0/kT)$

• Junctions and band structure

- Equilibrium at atomic scale (in metals):





• Junctions and band structure

- Equilibrium at atomic scale (in semiconductors)



• Number of electrons in the conduction band



 $n_{\rm n} = N_{\rm o} \exp[-(E_{\rm g} - E_{\rm F})/kT]$ $n_{\rm p} = N_{\rm c} \exp\{-[(E_{\rm g} + eV_{\rm 0}) - E_{\rm F}]/kT\}$ $n_{\rm n}/n_{\rm p} = \exp(eV_{\rm 0}/kT)$

• If all the impurities are ionized ($n_n \approx N_d$ and $p_p \approx N_a$):

$$V_0 \simeq \frac{kT}{e} \log_e \left(\frac{N_d N_a}{n_i^2}\right)$$

• Consider a uniform sC biased with a voltage V:



The whole band structure tilts (one end of the sC has more energy than the other).

Electrons and holes move in the field (in opposite directions.

• Consider a junction biased with a voltage V:



• Excess carriers in a biased junctions:



 $p_{\rm p} = p_{\rm n} \exp(eV_0/kT)$

$$p_{n0} = p_p \exp[e(V - V_0)/kT]$$

$$p_{n0} = p_n \exp(eV/kT)$$

 $n_{\rm p0} = n_{\rm p} \exp(eV/kT)$

• Excess carriers in a biased junctions:



(a) a hole current density, J_{hp} , flowing from the p-region; (b) a hole current density, J_{hn} , flowing from the n-region; (c) an electron current density, J_{en} , flowing from the n-region; (d) an electron current density, J_{ep} , flowing from the p-region.

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